

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	8	(US-20030073288-\$ or US-20020168850-\$ or US-20040081715-\$).did. or (US-6734113-\$ or US-6281050-\$ or US-6074908-\$ or US-6780715-\$ or US-6314023-\$).did.	US-PGPUB; USPAT	OR	ON	2005/10/07 19:24
L2	38	("5918133" "5926708" "6009023" "6033943" "6063670" "6080682" "6110842" "6133164" "6140185" "6171911" "6232244" "6261972" "6262455" "6297103" "6339001" "6465323" "6472740" "6573192" "6579766").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 19:24
L3	38	L2 not 1	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 19:24
S2	38	("5918133" "5926708" "6009023" "6033943" "6063670" "6080682" "6110842" "6133164" "6140185" "6171911" "6232244" "6261972" "6262455" "6297103" "6339001" "6465323" "6472740" "6573192" "6579766").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/03 19:40
S3	2	("20050118764").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/04 11:19
S5	991992	@ad> "20031127" @rlad> "20031127" @pt1d> "20031127"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:21
S6	770	first adj gate adj oxide with second adj gate adj oxide not S5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:20
S7	66	sacrificial adj hard adj mask	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:21
S8	0	S6 and S7	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:21
S9	12528	hard adj mask	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:21
S10	8	S6 with S9	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:38
S11	1276	first adj gate adj oxide and second adj gate adj oxide not S5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:39
S12	0	S7 and S11	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:39
S13	47	S9 and S11 not (S5 S10)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:39
S14	160220	polycrystalline adj silicon polysilicon poly adj si not S5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:42
S15	41	S13 and S14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 11:43
S16	36	("5395778" "5472892" "5573980" "5668035" "5668065" "5843817" "5863820").PN. OR ("6074908").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/04 15:51
S17	36	S16 not S5	US-PGPUB; USPAT; USOCR	OR	ON	2005/10/04 16:19
S23	5921	438/241,253,258,279,286,592,926.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 16:49

S24	5616	S23 not S5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/04 16:49
S25	86	S6 and S24	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:11
S26	38	("5918133" "5926708" "6009023" "6033943" "6063670" "6080682" "6110842" "6133164" "6140185" "6171911" "6232244" "6261972" "6262455" "6297103" "6339001" "6465323" "6472740" "6573192" "6579766").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:11
S27	991992	@ad>"20031127"@iad>"20031127"@ptid>"20031127"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:11
S28	2	(germanium ge) and S26 not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:13
S29	770	first.adj gate adj oxide with second.adj gate adj oxide not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:13
S31	562845	germanium ge not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:15
S32	2	S29 with S31	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:17
S33	3	(mask\$4 cap\$4) with S31 and S29	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 09:20
S34	6	S29 and S26 not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 10:38
S36	1618	oxide with highl adj k not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 10:39
S37	5	S29 and S36	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:19
S38	126	S29 with (material composition different)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:20
S39	95	S29 with different	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:20
S40	1	S29 with different adj (material composition)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:28
S41	4492	high adj k not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:28
S42	0	S39 and 17y	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:29
S43	1	S39 and S41	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 16:30

S44	32	S29 with (material composition)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:13
S45	5489	plasma adj oxidation UV adj oxidation atomic adj layer adj deposition not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:14
S46	137	S41 with S45	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:14
S47	0	S46 with S29	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:16
S48	0	S46 and S29	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:15
S49	6591	first with second with gate adj oxide not S27	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:15
S51	0	S46 with S49	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:17
S52	2	gate adj oxide with S46	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/05 17:17